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(12) **United States Design Patent**
Hanson et al.

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(54) **TARGET PROFILE FOR A PHYSICAL VAPOR DEPOSITION CHAMBER TARGET**

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(**) Term: **15 Years**

(21) Appl. No.: **29/618,685**

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Related U.S. Application Data

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(51) **LOC (11) Cl.** **13-03**

(52) **U.S. Cl.**
USPC **D13/182**

(58) **Field of Classification Search**
USPC D13/182; D15/144.1, 144.2, 199
CPC H01L 21/67742; H01L 21/0226; H01L 21/02263; H01L 21/02266; H01L 21/02269; H01L 21/02271; H01L 2224/75186; H01L 2224/761185; H01L 2224/76186; H01L 2221/68363
See application file for complete search history.

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† cited by third party

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(57) **CLAIM**

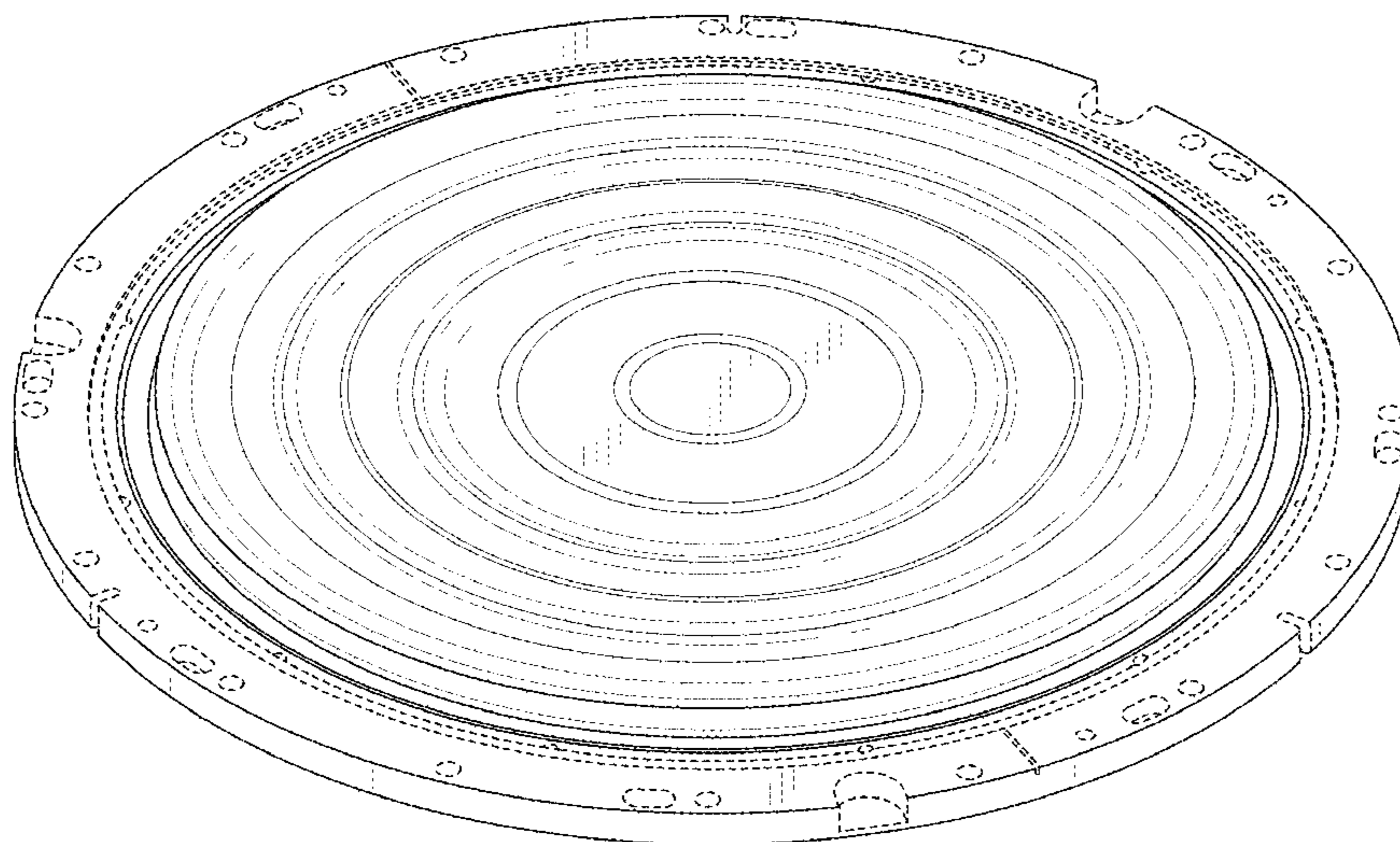
We claim the ornamental design for a target profile for a physical vapor deposition chamber target, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a target profile for a physical vapor deposition chamber target, showing our new design; FIG. 2 is a top plan view thereof; FIG. 3 is a bottom plan view thereof; FIG. 4 is a right side plan view thereof; FIG. 5 is a left side plan view thereof; FIG. 6 is a front view thereof; FIG. 7 is a back view thereof; and, FIG. 8 is a cross sectional view taken along line 8-8 in FIG. 2.

The dashed lines in FIGS. 1-8 represent disclaimed matter forming no part of the claimed design.

1 Claim, 6 Drawing Sheets



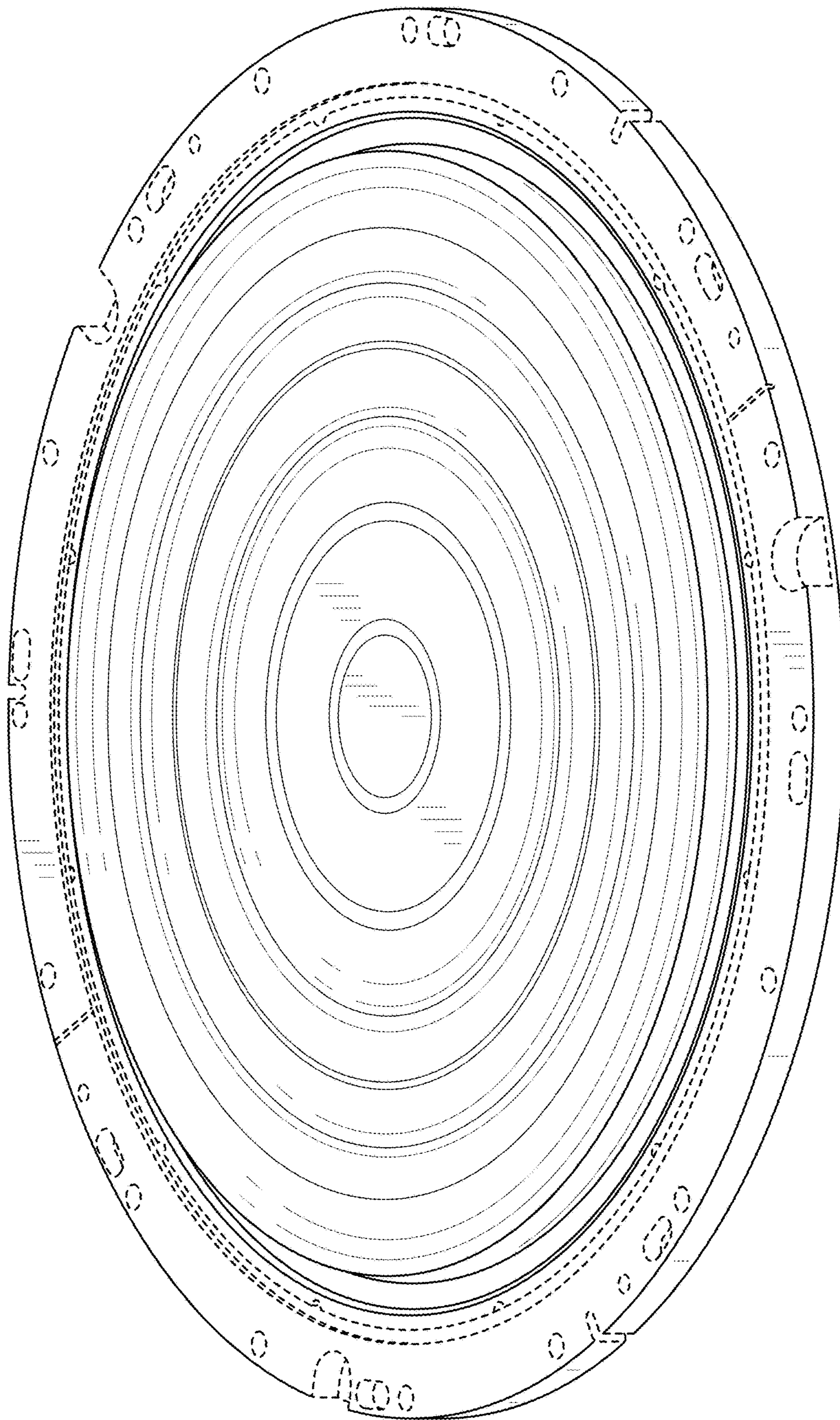


FIG. 1

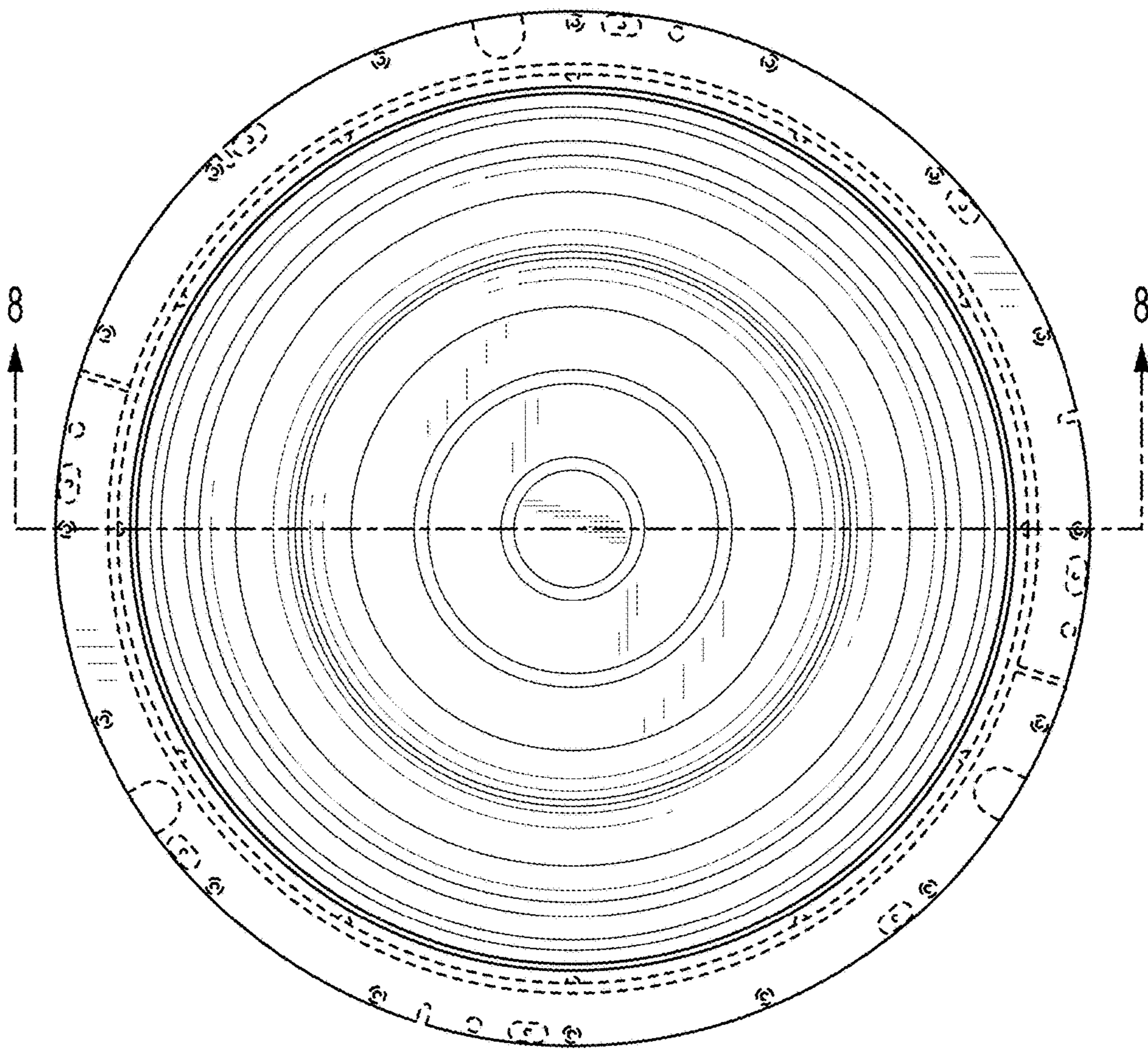


FIG. 2

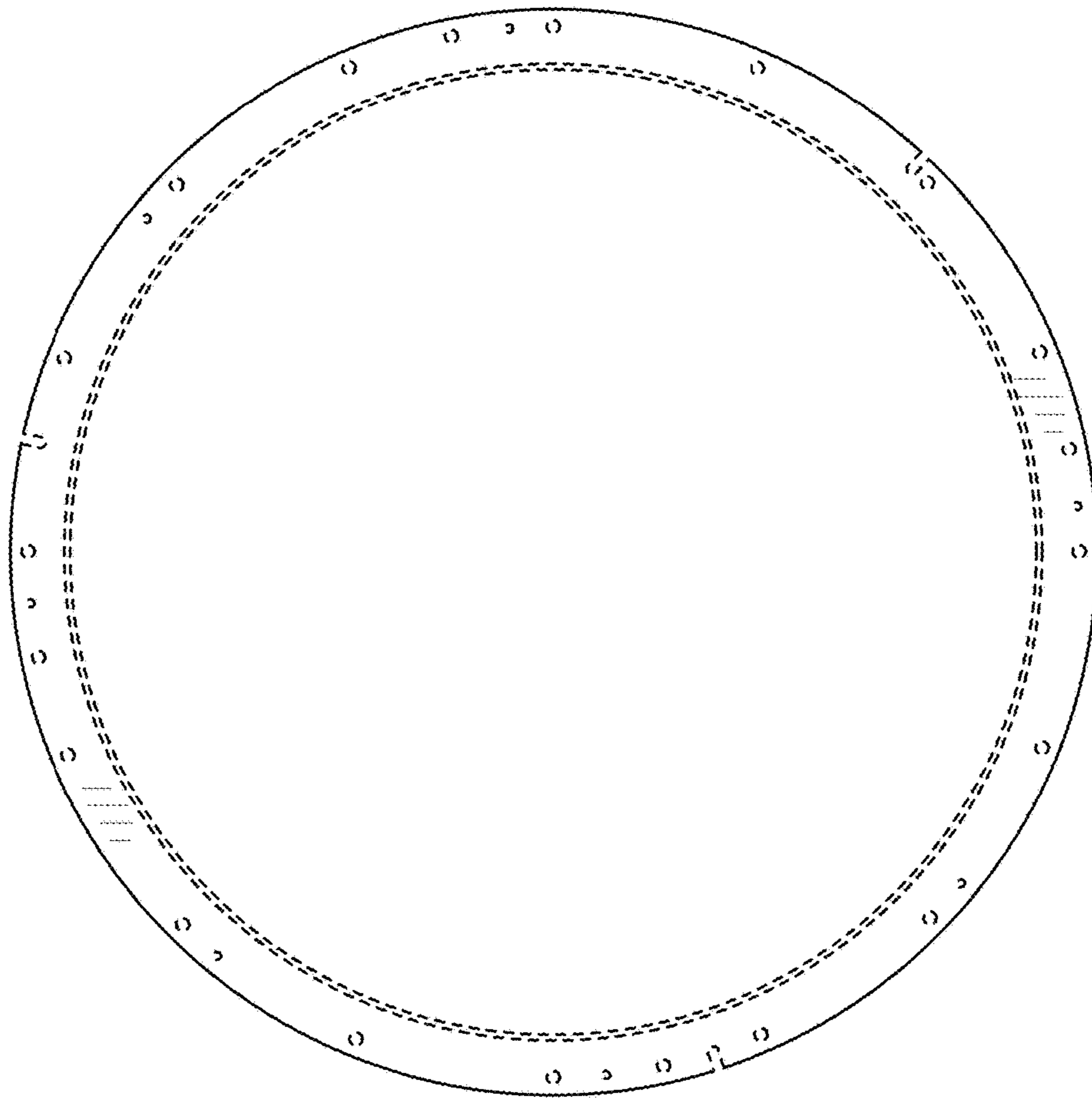


FIG. 3



FIG. 4

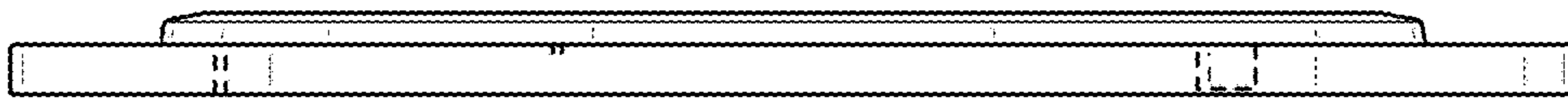


FIG. 5

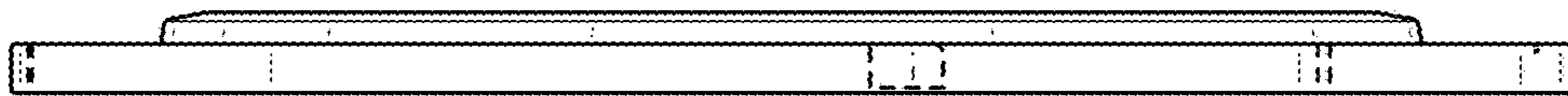


FIG. 6



FIG. 7

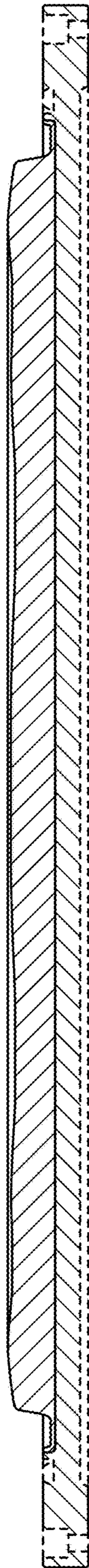


FIG. 8